

PROCEEDINGS OF SPIE

Micro-Optics 2016

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4–5 April 2016
Brussels, Belgium

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Volume 9888

Proceedings of SPIE 0277-786X, V. 9888

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Micro-Optics 2016, edited by Hugo Thienpont, Jürgen Mohr, Hans Zappe,
Hirochika Nakajima, Proc. of SPIE Vol. 9888, 988801 · © 2016 SPIE
CCC code: 0277-786X/16/\$18 · doi: 10.1117/12.2244185

Proc. of SPIE Vol. 9888 988801-1

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Author(s), "Title of Paper," in *Micro-Optics 2016*, edited by Hugo Thienpont, Jürgen Mohr, Hans Zappe, Hirochika Nakajima, Proceedings of SPIE Vol. 9888 (SPIE, Bellingham, WA, 2016) Six-digit Article CID Number.

ISSN: 0277-786X
ISSN: 1996-756X (electronic)
ISBN: 9781510601338

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445
SPIE.org

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